

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re United States Patent Application of:

Docket No.: 020732-110.694

Applicant: **KORZENSKI, Michael B., et al.**

Examiner: AHMED, Shamim

Application No.: 10/807,858

Art Unit: 1765

Date Filed: March 24, 2004

Confirm. No.: 5492

**Title: COMPOSITION USEFUL FOR
REMOVAL OF BOTTOM
ANTI-REFLECTION
COATINGS FROM
PATTERNED ION-
IMPLANTED PHOTORESIST
WAFERS**

Customer No.:

24239

RESPONSE TO THE MAY 2, 2007 OFFICE ACTION AND REQUEST FOR A ONE-MONTH EXTENSION UNDER 37 CFR §1.136(a) IN UNITED STATES PATENT APPLICATION NO. 10/807,858

Mail Stop Amendment
Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450

Sir:

This responds to the May 2, 2007 Office Action in the above-identified application.

The claims of the application are set out in the following **Section I (The Claims)**.

Remarks addressing the substance of the May 2, 2007 Office Action are set out in the **Section II (Remarks)** hereof.